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Author: Mathias Weiser Claudia Schulze Michael Schneider

Alexander Michaelis

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Platinum electrodeposition from a dinitrosulfatoplatinate(II) electrolyte

Mathias Weiser, Claudia Schulze, Michael Schneider, Alexander Michaelis

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Fraunhofer Institute for Ceramic Technologies and Systems, IKTS, Winterbergstr. 28, 01277 Dresden, Germany

Alexander Michaelis

TU Dresden, Institute of Material Science, Helmholtzstr. 7, 01069 Dresden, Germany

Corresponding author: Michael.Schneider@ikts.fraunhofer.de, +49 351 2553-7793, Dr.-Ing.

Highlights

Deposition of Pt-nanoparticles from a halogenic free electrolyte by pulse plating

The size of smallest Pt-particles is approximately 5nm

• The diffusion coefficient of the [Pt(NO2)2SO4]2--complex amounts to 5.4*10-6 cm2s-1.

High catalytic sensitivity

Abstract

In this work a halogenic-free electrolyte to deposit platinum nanoparticle is studied. The investigated

[Pt(NO₂)₂SO₄]²-complex is suitable for electrochemical deposition on halogenic sensitive substrates. The

mechanism and kinetic of particle deposition is investigated using a glassy carbon rotating disk electrode. Nano

sized platinum particles are deposited by using pulse plating technique. The size of the smallest platinum

nanoparticle is 5 nm. The shape of the particle distribution strictly depends on the plating time. The platinum

deposition is usually superimposed with hydrogen evolution. A diffusion coefficient of the

[Pt(NO₂)₂SO₄]²-complex is determined to 5.4*10⁻⁶ cm²s⁻¹. The current efficiency depends on the deposition

parameters and amounts to 37% under the chosen pulse plating conditions.

Keywords: platinum, electrodeposition, nanoparticles, pulse plating

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